Kinetics of electroplating process of nano-sized ceramic particle/Ni composite

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Abstract

Ultra-fine Al₂O₃, ZrO₂ and SiC powders were co-deposited with Ni by electroplating from a nickel sulfamate bath. An electroplating additive Na₃Co(NO₂)₆ can promote the co-deposition of the SiC particles, but the Al₂O₃ and ZrO₂ particles can form composite layers without the assistance of the additive. It suggests that the complex ion Co(NO₂)₆³⁻ acts as a catalyst during the composite plating. The Guglielmi adsorption mechanism is applied to the electroplating of the ultra-fine SiC with Ni. The ultra-fine SiC particles are more difficult to co-deposit than the coarse SiC, and the rate determination step is controlled by the transferal process of loose adsorption to strong adsorption. The embedded SiC concentration can be increased either by increasing electrical current density or by raising the pH of the suspension to 5. The existence of second ceramic phases in the co-deposited layer changes the grain shape of Ni from columnar to equiaxial, and reduces the average grain size of Ni-matrix to 50 nm.

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1. Introduction

Composite coating has been well developed for the last two decades, dating from the first investigation in the literature by Grazen [1] in 1962. Its first application was the SiC/Ni coating used as the wear-resistant improvement in the Wankel engine by Metzger et al. [2] in 1970, and the SiC/Ni composite coating is still successfully used for the wear parts in the automotive industry.

The advantages of this composite coating are clear. The simultaneous deposition of the non-metal inclusions and metal phases to form composite layers brings a significant improvement on several physical and mechanical properties of the coating. The ceramic particles whose use is reported in the literature [3–9] include Al₂O₃, SiC, Cr₂O₃, TiO₂, MoS₂, WC, etc. In addition, polymer particles such as polytetrafluoro-ethylene (PTFE) and polyethylene (PE) have also been used to reduce the friction coefficient and to achieve the anti-stick surface of the composite [10,11].

In many applications, such as hard coatings for precision molds or electroforming in the LIGA process, a co-deposition of ultra-fine particles with metal is preferable to coarse particles. From our previous investigation [12], the ultra-fine SiC/Ni composite has a smoother surface and better bonding between SiC and Ni than that of coarse SiC/Ni composite. For SiC particles larger than 0.1 μm, there often is an SiO₂ layer on the SiC particles which is weakly bonded to the Ni substrate, resulting in pores and cracks at the interface. In contrast, the interface of the ultra-fine SiC and Ni is integrated, with an interface that is free from defects. According to the Zener equation, based on the same volume particle content, the ultra-fine particles have higher numbers to inhibit the grain growth of the matrix at high temperatures.

However, there has been much research showing that the reduction of particle size will decrease the co-deposition content of the particles. Maurin and Lavanant [13] showed that the concentration of 0.1 μm of SiC powder incorporation in rotating disc experiments in a nickel sulfate solution was less than 0.7 mass% which was closed to the detection threshold of EDX analysis. On the contrary, the concentration can reach 2 mass% with SiC in size of 0.8 μm and 5 mass% with 2.8 μm. Fruensager et al. [11] quantitatively predicted the correlation of the concentration of PE particles engulfed in copper matrix on a rotational disc electrode based on trajectory analysis. According to their model, the quantity required to co-deposit 5 μm particles was calculated to be 10 times smaller than that of 20 μm particles.
Although the applications of hard metal coatings deposited by electroplating methods have been developed for a long time, the co-deposition mechanisms are still not yet well resolved. Guglielmi [3] is the first to propose a successive two-step adsorption mechanism, explaining the results related to the volume fraction of co-deposited particles \( \alpha \) to the volume percent of particles suspended in the plating bath \( C \) with the Langmuir adsorption isotherm. The first step in his mechanism is called loose adsorption, where particles have loose physical adsorption on the cathode with a high degree of metal ion coverage. In this step, there is a layer of adsorbed ions and solvent molecules, screening the interaction between the electrode and the particles. The second step is a strong adsorption, which is thought to be assisted by the electric field, whereby a substantially electrochemical reaction produces a strong adsorption of powders onto the electrode. The strongly adsorbed particles are then progressively engulfed by the growing metallic layer.

The mathematical model can be expressed as:

\[
\frac{C}{\alpha} = \frac{M_0}{nF\rho_{M0}} \exp(A - B) \left( \frac{1}{T} - C \right)
\]

where \( M \) is the atomic weight of the electrodeposited metal, \( \rho \) the exchanging current density, \( n \) the valence of the electrodeposited metal, \( F \) the Faraday constant, \( \rho_{M0} \) the density of electrodeposited metal, \( \eta \) the overpotential of electrode reaction, \( \eta = (i_0/i) \exp(An) \) the Langmuir isotherm constant, mainly determined by the intensity of interaction between particles and cathode. The parameters \( i_0 \) and \( B \) are related to particle deposition, and both play a symmetrical role with the parameters \( i_0 \) and \( A \) related to metal deposition.

The validity of Guglielmi’s model has been verified with different deposition systems, such as S/C and TiO\(_2\) particles with nickel from the nickel sulfate bath [3], or \( \alpha \)-Al\(_2\)O\(_3\) particles with copper from a copper sulfate plating bath [14, 15]. In this study, we investigate the behaviors of composite plating of ultra-fine Al\(_2\)O\(_3\), ZrO\(_2\) and SiC powders with Ni to form composite coatings. The Guglielmi adsorption model was applied to analyze the kinetics occurring during deposition in order to differentiate the behaviors of coarse and ultra-fine particles. Moreover, the influence of the co-deposited SiC contents by the plating parameters such as solid loadings of powder, current density, pH and composition of the plating bath were also investigated.

2. Experimental procedure

Three ultra-fine ceramic powders were used in this study. One is a plasma-synthesized ultra-fine SiC powder (PL-D-H-ZrO\(_2\), Wah Lee, Taiwan). The ultra-fine SiC showed a major phase \( 6\)H and the average particle size was 62 nm. The Al\(_2\)O\(_3\) powder has an average 30 nm particle size and \( \delta \)-phase. The average particle size and phase of the ZrO\(_2\) powder is 60 nm and cubic phase.

For the composite plating, unless specified in the text, a nickel sulfate bath containing 90 g l\(^{-1}\) nickel sulfate (EP grade, Phibrochem, USA), 3 g l\(^{-1}\) nickel chloride (EP grade, SHOWA, Japan), 40 g l\(^{-1}\) boric acid (EP grade, SHOWA, Japan), and \( 1 \times 10^{-4} \) M of sodium hexanitrocobaltate (NaC\(_{12}\)NO\(_{22}\)), EP grade, Alfa Aesar, MA) were added to the SiC/Ni composite plating bath. A Cu plate as cathode with dimensions of 10 mm \( \times \) 6.5 mm \( \times \) 0.25 mm was used and the anode used a Ti basket containing small nickel ingots. Before plating, a sequence of cleaning and acidic etching of the Cu plate by diluted sulfuric acid was applied to remove contamination and grease on the surface.

The solid loading of the added powder in plating solution was up to 1.5 vol.% based on the bath volume. Gentle stirring of suspension by air bubbles kept the solution well dispersed. The current density was applied from 0.15 to 8 A dm\(^{-2}\) (ASD). The bath temperature from 25 to 50 °C was controlled within 2° C and the pH ranged from 2.0 to 6.0, as was adjusted by H\(_3\)BO\(_3\) or NaOH.

An electrophoretic mobility meter (Laser Zee meter 501, Pen Ken, NY) and an electrokinetics charge analyzer (ECA2000, Chemtrac Systems, GA) were used for the measurement of the \( \zeta \)-potential and streaming current (SC) readings, respectively. The co-deposition layer was cut and polished, and then a thin foil sample of 3 mm diameter prepared from the coating layer was prepared and characterized by transmission electron microscopy (TEM or HRTEM, 100CXII, FX-400E, JEOL, Japan).

3. Results and discussion

3.1. Surface potential of ultra-fine particles

The SC readings of ultra-fine Al\(_2\)O\(_3\) and ZrO\(_2\) particles suspended in nickel sulfate plating bath at different temperatures are shown in Fig. 1. The two powders are positively charged and their SC readings are nearly constant as the temperature of the plating solution is increased. The isoelectric point (IEP) of Al\(_2\)O\(_3\) and ZrO\(_2\) are pH 9 and 6 \([16, 17]\), respectively. The IEP of the two powders is larger than the pH of the plating suspension (pH = 4). Contrarily, The IEP of SiC is 3 \([12]\). Theoretically, the particle surface should be negatively charged in an aqueous solution of pH = 4. But further investigation revealed that SiC with negative charged surface would adsorb Ni\(^{2+}\) ions and change the surface polarity from negative to positive as shown in Fig. 2. Due to the increased concentration of nickel sulfate, the adsorbed density of Ni\(^{2+}\) ions on the surface of SiC increases. Finally, it results in the increase of \( \zeta \)-potential at high concentration of Ni electrolyte.
3.2 Influence of sodium hexanitrocobaltate

A small addition of Na₃Co(NO₂)₆ can promote the co-deposition of ultra-fine SiC particles as shown in Fig. 3. Only 0.3 vol.% of SiC was co-deposition in the Ni matrix in the suspension without any Na₃Co(NO₂)₆. When 2 × 10⁻⁵ M of Na₃Co(NO₂)₆ was added to the plating bath, the embedded SiC concentration in Ni layer increased by about 20 times. However, further addition of Na₃Co(NO₂)₆ did not seem to increase the SiC concentration. With the concentration higher than 20 × 10⁻⁵ M, the coating surface lost its burnish and the layer delaminated. Fig. 4 shows the SEM micrographs of ultra-fine SiC/Ni composites with or without the addition of Na₃Co(NO₂)₆. For the SiC/Ni composite plating without Na₃Co(NO₂)₆, few SiC particles were found in the matrix and showed cluster state. The cluster structure could be regarded as an agglomeration-like structure, and the particles inside the clusters were not in contact with each other. When 1.5 × 10⁻⁵ M of Na₃Co(NO₂)₆ was added to the plating solution, the content of SiC particle in the Ni matrix increased and the distance among the SiC particles was uniform. As the concentration reached 15 × 10⁻⁵ M, the embedded SiC increased further and reached a saturation level. The number of cluster structure obviously increased and the distance among the particles inside the cluster decreased.

When Na₃Co(NO₂)₆ is dissolved in water, the cation Na⁺ and anion [Co(NO₂)₆]³⁻ are readily formed in the solution. The anion [Co(NO₂)₆]³⁻ might be adsorbed on the top of Ni²⁺ cation and neutralize the particle charge. Thus, the anion seems to decrease the surface potential of SiC particle and the van der Waals attractive force dominates the particle’s interaction. Therefore, the distance between SiC particles decreases with an increase in the concentration of [Co(NO₂)₆]³⁻.

Consequently, it is suggested that the trivalent Co complex ion acts as a catalyst during the composite plating, assisting the adsorption of SiC on the cathode. But a high concentration of the trivalent anion causes the SiC particles to form a cluster structure and to decrease the distance among the SiC particles in the Ni matrix.

3.3 Adsorption kinetics of SiC/Ni

Fig. 5 shows that the volume percentage of embedded SiC (α) increases as the concentration (C) of the SiC in the
Fig. 4. SEM micrographs of ultra-fine SiC/Ni composite plating by adding:
(a) 0 M; (b) $1.5 \times 10^{-5}$ M; (c) $15 \times 10^{-5}$ M of Na$_3$Co(NO$_2$)$_6$.

suspension, referred to as an adsorption isotherm curve. According to the co-deposition model proposed by Guglielmi, Fig. 5 can be re-plotted showing $C/\alpha$ vs. $C$ at various current densities as shown in Fig. 6. Based on Eq. (1), the relationship of $C/\alpha$ and $C$ can be fitted as a straight line, which has a interception $(1/k)$ with $C$-axis. The slope ($\tan \phi$) of the line is given by

$$
\tan \phi = \frac{M_0 \exp(A - B)\eta}{nF\rho m v_0}
$$

(2)

The intercept of the line conducted for the condition $i = 4$ ASD shows a value $-0.46$, which gives the constant $k$ to be 2.14 for ultra-fine SiC particles co-deposited with Ni electrode. Here, $k$ indicates the net reaction constant of the particle adsorbed on the electrode surface and can be expressed as $k = k_a/k_d$, where $k_a$ is the adsorption coefficient and $k_d$ is the desorption coefficient of particles on the electrode. If $k > 1$, it indicates that the adsorption rate of particles is faster than desorption rate, and vice versa. With the coarse SiC particles in an average size of 2 $\mu$m [3], the $k$ value is 8.3, which is larger than that of this study for ultra-fine SiC.

Fig. 5. Relationship of SiC contents in the suspension and in the composite coating. The composite plating conducted at value of pH = 5 at 50°C.

Fig. 6. Co-deposition of ultra-fine SiC and Ni according to Eq. (1) for various current densities.
This implies that the adsorption on the electrode surface of ultra-fine SiC particles is much more difficult than that of the coarse SiC particles. Once the $k$ value is obtained, the coverage of loose adsorption ($\sigma_l$) particles and strong adsorption ($\sigma_s$) can also be computed by the Langmuir adsorption isotherm modified by Guglielmi [3] as:

$$\sigma_l = \frac{kC}{1 + kC}(1 - \sigma_s)$$  \hspace{1cm} (3)

where we assumed that surface coverage of strong adsorption is close to the volume fraction of the particle ($\alpha$).

Therefore, the loose adsorption coverage can be estimated by Eq. (3) and the results are shown in Table 1. The coverage of loosely adsorbed SiC is greater than the concentration of particles in the suspension. Furthermore, only one-tenth of the loosely adsorbed particles can be trapped into the matrix by their reduction of metal ions adsorbed on the particle surface, and consequently the particles become strongly adsorptive. As a result, the rate determined step in the co-deposition of SiC in the Ni sulfamate bath is controlled by the transferred process of loose adsorption to strong adsorption.

From Eqs. (1) and (2), Guglielmi deduced Eq. (4) concerning the relationship of slope $\tan \phi$ and the current density $i$ as:

$$\log \tan \phi = \log \frac{M_{\text{Ni}} R_i}{nF_{\text{Faraday}}} + \left(1 - \frac{B}{A}\right) \log i$$  \hspace{1cm} (4)

The results of $\tan \phi$ vs. current density between 0.15 and 8 ASD are shown in Fig. 7. The linear fitting line is plotted in the figure, and the slope of the line is $-0.44$. Therefore, $B/A$ is 1.44 in Eq. (4). There are two electrodic reactions for the composite plating. One is the metal ions diffusing through the outer Helmholtz plane (OHP) [18] of electrode, being reduced and depositing on the cathode. The other is that the charged particles pass through the OHP and adsorb on the cathode. The constants $A$ and $B$ can be seen as the total charge passing through the electrode interface and carried by Ni$^{2+}$ ions and charged SiC during the reaction. If $B > A$, it indicates that the current density increases as the concentration of SiC in the plating layer increases. The relation of current density and SiC content in the coating layer was shown in Fig. 8. The SiC contents increase abruptly as the current density increases to $\leq 2$ ASD. When the current density increases to $\geq 3$ ASD, the increment of SiC content slows down to a level of 7–8 vol.%.
charged particle will have a velocity \((v_E)\) in an electric field and can be expressed as:

\[ v_E = u_E E = \frac{\varepsilon \zeta}{\eta} E \]  

where \(E\) is applied field strength, \(u_E\) the electrophoretic mobility and \(\eta\) the viscosity of the suspension. Two different processes for the co-deposition of SiC can be considered. One is the electrophoresis of particles near the electrode, and the other is the adsorption of the particle together with Ni on electrode. If the \(\zeta\)-potential increases, the electrophoretic mobility velocity of the SiC particles increases. It implies that the concentrations of the SiC in the suspension near the electrode are higher than that under a low \(\zeta\)-potential condition. The increment of the coverage of loose adsorption suggests that these particles have a higher opportunity of transferring to strong adsorption.

3.4. Microstructure of composite layers

Fig. 10 shows the TEM micrograph of the cross-section of the Al\(_2\)O\(_3\)/Ni composite coating, with a few clusters of Al\(_2\)O\(_3\) particles embedded in Ni matrix. The diffraction pattern (DP) shows a ring pattern, which indicates that the Ni grains are polycrystalline and very small. A similar microstructure was found in ZrO\(_2\)/Ni and SiC/Ni composites, which are shown in Figs. 11 and 12, respectively. For the ultra-fine ZrO\(_2\) powders, it is difficult to disperse the particles in a highly concentrated electrolyte. Therefore, from Fig. 11(a), ZrO\(_2\) agglomeration containing particles smaller than 20 nm is found in the Ni matrix, and there are some pores entrapped in the agglomerate. The attached DP shows a very weak ring pattern which is indexed as cubic phase.
ZrO$_2$. Fig. 12(a) and (b) are the bright field (BF) and centered dark field (CDF) images, showing the Ni grain of SiC/Ni composite. The average grain size of Ni is 50 nm and equiaxial in shape. The Ni grain in the pure Ni specimen shows a columnar texture with a longitudinal axis or growth direction perpendicular to the Cu substrate [12]. However, when the ultra-fine ceramic particles are added into the Ni matrix to form composites, the grain size and shape of the Ni are greatly reduced and modified. In addition, the shape of the Ni becomes equiaxial due to the presence of the second phase.

4. Conclusion

Nano-sized Al$_2$O$_3$ and ZrO$_2$ particles can be co-deposited with Ni to form composite layers without the assistance of additive. This is because the surface charge of the powders is positive when their IEPs are larger than the pH of suspension. Trivalent Co complex ions, i.e. Co(NO$_2$)$_6$$_{3^{-}}$ can promote the co-deposition of ultra-fine SiC particles. It is suggested that the complex ions act as a catalyst during the composite plating. The two-step co-deposition mechanism proposed by Guglielmi is valid in the ultra-fine SiC/Ni composite plating. The results show that the ultra-fine SiC is more difficult to co-deposit than the coarse SiC, and the rate determined step is controlled by the transferring process of loose adsorption to strong adsorption. The embedded SiC concentration can be increased by increasing the current density or raising the pH of the suspension. The existence of second ceramic phases changes the Ni grains from columnar to equiaxial shape, and consequently reduces the grain size.

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